TRENTO Workshop, March 2022

Magdalena Munker on behalf of the MONOLITH team.

Picosecond time stamping in fully monolithic highly granular silicon pixel detectors

funded by the H2020 ERC Advanced grant 884447





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SiGe BiCMOS front end technology





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SiGe HBT = BJT with Germanium as base material:

- \rightarrow higher doping in base possible
- \rightarrow thinner base
- \rightarrow reduced base resistance R_b

Grading of Ge doping in base:

ightarrow charge transport in base via drift

- \rightarrow reduced charge transit time in base
- \rightarrow high current gain β

$$ENC_{series\ noise} \propto \sqrt{k_1 \frac{C_{tot}^2}{\beta} + k_2 R_b C_{tot}^2}$$

Leading-edge technology IHP SG13G2, 130 nm process featuring SiGe HBT with:

- Transistor transition frequency: *ft* = 0. 3 *THz*
- DC Current gain: $\beta = 900$
- Delay gate: 1.8 ps
- \rightarrow Implemented in silicon sensor
- \rightarrow Used for pre-amplifier and drivers



innovations for high performance microelectronics

Leibniz-Institut für innovative Mikroelektronik

The MONOLITH team at UniGe



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Giuseppe lacobucci • project P.I.

System design



Didier Ferrere

 System integration Laboratory test



Pierpaolo Valerio Lead chip design

Digital electronics



Mateus Vicente

 System integration Laboratory test



Yana Gurimskaya Radiation tolerance Laboratory test



Stefano Zambito Laboratory test

Stéphane Débieux Board design RO system





Antonio Picardi Chip design

Théo Moretti

Laboratory test

Laboratory Test

Lorenzo Paolozzi

- Sensor design
- Analog electronics



Sergio Gonzalez-Sevilla

- System integration
- Laboratory test



Magdalena Munker

- Sensor design
- Laboratory test

Roberto Cardella

- Sensor design
- Analog electronics







· Board design RO system











Main research partners:



Roberto Cardarelli INFN Rome Tor Vergata







Holger Rücker IHP Mikroelektronik



Mehmet Kaynak IHP Mikroelektronik

Ivan Peric KIT



Bernd Heinemann IHP Mikroelektronik

Wide range of activities:

Chip design and simulation, sensor design and simulation, sensor + chip testing in probe station, climate chamber, test-beam,...

https://www.unige.ch/dpnc/en/groups/giuseppeiacobucci/research/monolith-erc-advanced-project/ 3











Hexagonal pixels with large collection electrode:

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- Homogenous drift field
- Reduced breakdown probability at pixel implant corners
- 100µm pitch
- 25µm p-type epitaxial layer

Four Matrices:

- 1. Active pixel
 - Front end in pixel
 - HBT preamp + driver (in pixel) + CMOS discriminator (outside pixel)
- 2. Active pixel v2
 - HBT preamp + CMOS discriminator
- 3. Limiting amplifier
 - HBT preamp + HBT limiting amplifier
- 4. Double threshold
 - HBT preamp + two CMOS discriminators

Analogue pixels of the ATTRACT chip



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MPW submission in 2019 funded by H2020:







4 analog channels include:

HBT preamp + two HBT Emitter Followers to 500Ω Resistance on pad.

\rightarrow Test of analogue channels to investigate HBT and sensor performance

Test beam results – performance for different sensor bias

CERN SPS 180GeV pion beam, FEI4 Telescope ($\sigma_x \sim 10 \mu m \sigma_v \sim 15 \mu m$), 2 DUTs for timing reference https://doi.org/10.1088/1748-0221/17/02/P02019



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Test beam results – performance for different pre-amp current





Particle Physics



CERN SPS 180GeV pion beam, FEI4 Telescope ($\sigma_x \sim 10 \mu m \sigma_v \sim 15 \mu m$), 2 DUTs for timing reference https://doi.org/10.1088/1748-0221/17/02/P02019



Time resolution as a function of preamplifier current:

- Power consumption dominated by preamplifier current
- Efficiency > 99.5% and time resolution below 80ps even at low preamplifier current of 20μ A

The MONOLITH ERC Advanced Project

5 year ERC project to develop:

Monolithic silicon sensor

able to measure precisely the 3D spatial position of charged particles while providing at the same time **picosecond time resolution**.



H2020 ERC Advanced grant 884447, July 2020 - June 2025

https://www.unige.ch/dpnc/en/groups/giuseppeiacobucci/research/monolith-erc-advanced-project/



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IHP SG13G2 electronics

PicoAD sensor concept

Picosecond Avalanche Detector (PicoAD): EU Patent EP18207008.6

Schematic view of PicoAD sensor concept:



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Placement of gain layer deep inside sensor:

De-correlation from pixel implant size/geometry

 \rightarrow High pixel granularity possible (spatial precision)

- Only small fraction of charge gets amplified
 - \rightarrow Reduced charge fluctuations (*timing precision*)

PicoAD – 3D TCAD structure







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Hexagonal collection electrodes





- 3D hexagonal pixel structure of pixels in matrix ٠
- \rightarrow Relevant for pixel corners, breakdown around p-stops and depletion and field in drift region
- Modelling of Si/Oxide interface (not presented here) ٠

PicoAD – 3D TCAD, electric field and depletion



2D cross section of 3D TCAD, electic field (color scale) and depletion (white line):



Depletion and electric field first build up in absobtion layer, when applying voltage to the backside

PicoAD – 3D TCAD, electric field and depletion



2D cross section of 3D TCAD, electic field (color scale) and depletion (white line):



-75V

Electrtic field and depletion in drift layer start to build up after depletion of gain layer

'Pockets' under p-stops in 2nd epitaxial layer deplete last

→ Relevance of 3D modelling and optimisation of inter-pixel region

PicoAD – 3D TCAD, electric field and depletion



2D cross section of 3D TCAD, electic field (color scale) and depletion (white line):



-140V

After full depletion the drift field in the 2nd epitaxial layer is build up

→ Important to saturate drift velocity

Planar field in drift and gain layer except for p-stop region

 \rightarrow Careful optimization necessary to fully deplet and build up field in drift

region while maintaining stable high field in gain layer.

55-Fe measurement concept







- Only carriers passing through the gain layer are multiplied
- Two different peaks for e⁻ and h⁺
- Measurements performed in climate chamber to investigate gain as a function of temperature

55-Fe climate chamber measurement results

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50 First Peak [mV] Dose 4 Wafer 9 Wafer 6 45 Preliminary T = -20°C 40 • T = -10°C T = +20°C 35 Dose 1 30 Wafer 9 25 ----- T = +20°C 20 15 10 5 80 85 95 100 105 110 115 120 125 130 135 140 145 90 HV [V]

First peak of the 55-Fe spectrum as a function of the High Voltage (HV):

Second peak of the 55-Fe spectrum as a function of the High Voltage (HV):



- Electron and hole gain increase with HV and temperature
- Clear difference between wafer 6 and wafer 9 for the same dose (under investigation)
- Lowest dose 1 shows almost no hole gain, used for normalization to get electron gain (next slide)

55-Fe climate chamber measurement results



e gain vs HV gain Dose 4 Wafer 9 Wafer 6 Preliminary 'a T = -20°C 20 - T = -10°C T = -10°C T = +20°C Dose 1 15 Wafer 9 10 80 85 90 95 100 105 110 115 120 125 130 135 140 145 HV [V]

- Gain up to above 20 for wafer 9
- Gain most likely underestimated due to space charge effects from high local charge from 55-Fe



- Consistent behaviour of the 3 samples
- Ratio of e/h-gain decreaseds at higher e-gain values (expected to saturate)
- Possible explanation: space charge effects

Space charge effects in picoAD double junction sensor

Transient 3D TCAD simulation of point like 55-Fe charge deposition in absorption layer:



- → Reduced e-gain for higher local charge densities (higher initial charges or higher field values in gain layer, resulting in larger number of multiplied charges)
- \rightarrow Transient field simulation necessary

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Test beam results for PicoAD

CERN SPS 180GeV pion beam, FEI4 Telescope ($\sigma_x \sim 10 \mu m \sigma_v \sim 15 \mu m$), 2 DUTs for timing reference





Efficiency as a function of preamplifier current:

Improved efficiency for prototype with gain layer, despite reduction of epitaxial thickness w.r.t. prototype with gain.

Time resolution as a function of preamplifier current:



 \rightarrow Proof of concept, not optimized for timing yet.

 \rightarrow Efficiency > 99.5% and time resolution ~40ps even at low preamplifier current of 20µA.

Picosecond TDC



Picosecond TDC test chip



Integrated in MONOLITH p1 Prototype: under test Improved TDC version back from foundry in April 2022.

Conclusion and outlook

- **Proof of concept of PicoAD sensor + HBT frontend:**
- > 99.9% efficiency ~25ps time resolution
- Study of fundamental electron-hole gain processes in multi junction sensor
- Development of picosecond TDC for fully monolithic MONOLITH chip
- Development of optimised sensor with TCAD

BACKUP